

<b>INFORMATION DISCLOSURE CITATION</b> <i>(Use several sheets if necessary)</i>	Docket Number (Optional) <b>SON5180.26A</b>	Application Number
	Applicant(s) <b>DAVID C. BOYDEN; RYUICHI IWAMURA</b>	
	Filing Date	Group Art Unit

**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		3,944,723	02/1976	Fong			
		4,796,027	01/1989	Smith-Vaniz			
		5,630,204	05/1997	Hylton et al.			
		5,392,223	02/1995	Caci			
		6,026,086	02/2000	Lancelot et al.			
		6,125,448	09/2000	Schwan et al.			
		6,243,818	06/2001	Schwan et al.			
		6,278,357	08/2001	Croushore et al.			
		6,492,897	12/2002	Mowery, Jr.			

**FOREIGN PATENT DOCUMENTS**

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO

**OTHER DOCUMENTS** *(Including Author, Title, Date, Pertinent Pages, Etc.)*


<b>EXAMINER</b>	<b>DATE CONSIDERED</b>
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**EXAMINER:** Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.